## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

)	Group Art Unit:
)	Examiner:
)	
)	Los Angeles, California
	) ) ) ) ) ) )

## INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner of Patents and Trademarks Alexandria, VA 22313

Sir:

Attached hereto is a PTO-1449 form listing documents believed relevant to the subject application. It is respectfully requested that these documents be considered by the Examiner and an initialed copy of each page of the form be returned to the undersigned.

It should be noted the word "prior" has been deleted from the form.

Attorney Docket No. 1465.08

It is believed that this disclosure complies with the requirements of 37 C.F.R. § 1.56 and the Manual of Patent Examining Procedure § 707.05(b). If, for some reason, the Examiner considers otherwise, it is respectfully requested that the undersigned be called so that any deficiencies can be remedied.

A copy of each document is enclosed.

Some of the documents may have markings thereon. No significance is meant to be attached to the markings.

These documents are not necessarily analogous art.

Respectfully submitted,

Park & Sutton LLP

Dated:  $\ell/28$  , 20

Bv:

Regis No. 37.90

FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE ATTORNEY DOCKET NO. 1465.08 SERIAL NO. PATENT AND TRADEMARK OFFICE LIST OF ART CITED BY APPLICANT (Use several sheets if necessary) APPLICANT: Choon Hwa Hwang FILING DATE: Herewith GROUP U.S. PATENT DOCUMENTS Examiner DOCKET NUMBER DATE CLASS SUBCLASS FILING DATE Initial IF APPROPRIATE AΑ D266,800 11/82 Kula et al. D3 214 AB 5,678,739 10/97 Darling et al. 224 158 5,791,535 08/98 Roan et al. 224 153 6,045,018 04/00 Onishi, Ichiro 224 158 ΑE AF AG AΗ ΑI AJ AΚ AI. AM AN ΑO ΑP AQ AR **FOREIGN PATENT DOCUMENTS** DOCKET NUMBER CLASS SUBCLASS DATE COUNTRY TRANSLATION YES NO ΑT OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.) ΑV NONE ΑW ΑX DATE CONSIDERED EXAMINER EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.